

TJK/180/L.W.

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of Hong-Sik BYUN et al. ) PLASMA PROCESSING APPARATUS  
Korean Appln. No. 2000-30050 )  
Korean Filing Date: June 1, 2000 )

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents  
Washington, D.C. 20231

Dear Sir:

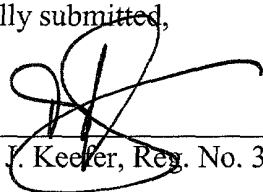
Please amend the subject application as follows:

**--CROSS REFERENCE TO RELATED APPLICATION**

This application claims the priority of Korean patent application Serial No. 2000-30050  
filed on June 1, 2000.-

Respectfully submitted,

Date: 5/31/01  
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By:   
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CERTIFICATE OF EXPRESSION

"Express Mail" mailing label number EL304145865 US  
Date of Deposit: 5/31/01  
I hereby certify that this paper or its is being deposited with  
United States Postal Service "Express Mail" for the  
Addressee" on the date indicated above and is deposited with  
Assistant Commissioner for Patents, Washington, D.C. 20231

